	L #	Hits	Search Text	DBs
1	L1	1351	430/321.ccls.	US-PGPUB; USPAT
2	L2	17914	waveguide.ti,ab.	US-PGPUB; USPAT
3	L3	124	1 and 2	US-PGPUB; USPAT
4	L4	289214	(polymer or organic or polymeric or photosensitiv$6 or photopolymeri$6 or photoresist or polymeriz$6 or polymeris$6 or resist).ti,ab.	US-PGPUB; USPAT
5	L5	1050	2 and 4	US-PGPUB; USPAT
6	L6	157	(oxygen$6 or deoxygen$6 or o2 or "o.sub.2") same (vacuum or pressure or inert or gas) and 5	US-PGPUB; USPAT
7	L7	60354	(partial$4 or incomplet$6 or full$4) with (polymeriz$6 or polymeris$6 or cure$1 or curing or harden$4)	US-PGPUB; USPAT
8	L8	127	5 and 7	US-PGPUB; USPAT
9	L9	555	385/143,145.ccls.	US-PGPUB; USPAT
10	L10	2151	385/129,130.ccls.	US-PGPUB; USPAT
11	L11	249072	(photosensitiv$6 or phoitopolymer$6 or photoresist or resist or expos$4 or irradiat$4 or radiat$4).ti,ab.	US-PGPUB; USPAT
12	L12	299	10 and 4	US-PGPUB; USPAT
13	L13	221	12 not (3 or 8 or 6)	US-PGPUB; USPAT
14	L14	228341	liquid.ti,ab.	US-PGPUB; USPAT

	L #	Hits	Search Text	DBs
15	L15	57	2 and 4 and 14	US-PGPUB; USPAT
16	L16	101	9 and 11	US-PGPUB; USPAT
17	L17	318327	proximity	US-PGPUB; USPAT
18	L18	2114	2 and 17	US-PGPUB; USPAT
19	L19	29666	17 with (imag$4 or expos$4 or mask$4 or photomask$4 or reticle or pattern$4 or photolith$10 or lithograph$6 or radiat$4 or irradiat$4)	US-PGPUB; USPAT
20	L20	310	2 and 19	US-PGPUB; USPAT
21	L21	21161	17 near8 (imag$4 or expos$4 or mask$4 or photomask$4 or reticle or pattern$4 or photolith$10 or lithograph$6 or radiat$4 or irradiat$4)	US-PGPUB; USPAT
22	L22	47	5 and 21	US-PGPUB; USPAT
23	L23	362010	mask$4 or photomask$4 or reticle	US-PGPUB; USPAT
24	L24	556895	oxygen$6 or deoxygen$6 or o2 or "o.sub.2"	US-PGPUB; USPAT
25	L25	10393	23 with 24	US-PGPUB; USPAT
26	L26	29	5 and 25	US-PGPUB; USPAT
27	L27	14	ferm-paul$4	US-PGPUB; USPAT
28	L28	3	battell-kevin$.in.	US-PGPUB; USPAT

	L #	Hits	Search Text	DBs
29	L29	45	beeson-karl$.in.	US-PGPUB; USPAT
30	L31	22	maxfield-macrae$.in.	US-PGPUB; USPAT
31	L32	55	shacklette-lawrence$.in.	US-PGPUB; USPAT
32	L35	7	pant-deepti$.in.	US-PGPUB; USPAT
33	L36	46	(27 or 28 or 29 or 31 or 32 or 35) and 2	US-PGPUB; USPAT

	L #	Hits	Search Text	DBs
1	L1	7416	waveguide.clm.	US-PGPUB
2	L2	114126	(polymer or organic or polymeric or photosensitiv$6 or photopolymer$8 or photoresist or polymeriz$8 or polymeris$8 or resist).clm.	US-PGPUB
3	L3	34714	(oxygen$6 or deoxygen$6 or o2 or "o.sub.2").clm.	US-PGPUB
4	L4	111	1 and 2 and 3	US-PGPUB
5	L5	1988	((partial$4 or incomplet$6 or full$4) with (polymeriz$6 or polymeris$6 or cure$1 or curing or harden$4)).clm.	US-PGPUB
6	L6	3	4 and 5	US-PGPUB